



INVITATION

March 09, 2021 | 13:00 - 16:15

Online-Symposium
»Functional Coatings, Manufacturing,
Metrology & Application«

Registration is requested until 08th of March, 2021.



Online-Symposium »Functional Coatings, Manufacturing, Metrology & Application« March 09, 2021

The online symposium takes place within the framework of the "Graphene" network coordinated by TH Wildau. The aim of the conference is the exchange of experience between experts from industry, research institutions and universities on the topic of functional layers and associated materials. The event offers the opportunity to learn and exchange ideas about materials synthesis, metrology and applications in this area of research and technology in the form of lectures, online poster contributions and discussions. It will also serve to discuss innovative project ideas and problem solutions among experts from industry and science and to initiate cooperations. Registration is requested until 8th of March 2021.

Also visit our postersession.

PROGRAM

13	.00	Wel	come

Sigurd Schrader

Technische Hochschule Wildau

13:05 Laser stimulated broadband emission of graphene

Wieslaw Strek

Polish Academy of Sciences, Wroclaw, Poland

Optimal polymer materials: nacomposites for waveguides and electrooptic polymers with phototuning

Leonid Goldenberg Fraunhofer IAP-PYCO, Wildau

13:45 Fabry-Pérot sensors for parallelised photoacoustic tomography

Claus Villringer

TH-Wildau

14:05 Functional Materials in Silicon-Photonics: More than Moore

Patrick Steglich

IHP GmbH-Leibniz-Institut für innovative Mikroelektronik, Frankfurt (Oder)

14:25 **Break**

14:55 Optical characterization of polymers, design and manufacture of microlenses for LEDs

Marko Gutke

TH-Wildau + resintec GmbH, Falkenberg (Elster) + EPIGAP Optronic GmbH, Berlin

15:15 MIR Ellipsometry - from fingerprint technology to in-depth optical analysis

Robert Meyer

SENTECH Instruments GmbH, Berlin

15:35 Biocompatible UV-NIL material for functional coatings in life science manufacturing

Mirko Lohse

micro resist technology GmbH, Berlin

15:55 ALD deposition of P and Sb doping sources for the diffusion into 3D germanium structures

Mindaugas Silinskas

Max-Planck-Institut für Mikrostrukturphysik, Halle (Saale)